Surface behaviors of monometallic and cobalt-containing rhodium catalysts on SiO₂ in relation to their catalytic properties for hydroformylation

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Summary — The interactions of supported Rh^0 and cobalt-promoted Rh^0 with the SiO_2 surface have been investigated by IR spectroscopy. The supported highly-dispersed rhodium particles derived by H_2 decarbonylation of $Rh_6(CO)_{16}/SiO_2$ are oxidized to isolated Rh^+ by surface OH^- via heating at 623 K under vacuum, which adsorbs CO to form $Rh^+(CO)_2$. The conventional reduction of a mixture of rhodium and cobalt compounds supported on SiO_2 is unlikely to give bimetallic RhCo particles and yield probably monometallic rhodium and cobalt particles. The interaction of Co^0 with Rh^0 in supported promoted catalysts suppresses the oxidation of Rh^0 . The results show that the Co^0 promoter plays an electron-donating role, thus increasing the electron density of rhodium particles. The electronic effect can be correlated with the observed promotion of catalytic ethylene hydroformylation. IR study also demonstrates that the bimetallic $RhCo_3$ cluster framework is retained intact on the SiO_2 surface from thermal decarbonylation of $RhCo_3(CO)_{12}$ under any atmosphere and $RhCo_3(CO)_{12}/SiO_2$ readily regenerated from $RhCo_3$ under CO at room temperature. In situ IR observations indicate that supported Rh^0 on Rh/SiO_2 is an active site for hydroformylation and $RhCo_3(CO)_{12}/SiO_2$ is responsible itself for the catalysis. Moreover, such a bimetallic cluster catalyst displays an enhanced activity for ethylene hydroformylation, about 20 times that of a $Rh_4(CO)_{12}/SiO_2$ -derived monometallic catalyst.

 SiO_2 -supported rhodium / rhodium oxidation / promotion of cobalt / SiO_2 -supported $RhCo_3(CO)_{12}$ / preservation of $RhCo_3$ / regeneration of $RhCo_3(CO)_{12}$ / hydroformylation

Résumé — Comportement de catalyseurs mono- et bimétalliques au rhodium et rhodium-cobalt supportés sur SiO2 en relation avec leur activité catalytique dans les réactions d'hydroformylation. Les interactions du Rh(0) et des mélanges bimétalliques Rh(0)-Co(0) avec une surface de SiO_2 ont été étudiées par spectroscopie IR. La décarbonylation de $Rh_6(CO)_{16}/SiO_2$ par l'hydrogène moléculaire conduit à des particules de Rh(0) finement dispersées sur le support qui sont ensuite oxydées en Rh(1) par les OH^- de surface après chauffage à 623 K. L'adsorption de CO conduit à la formation de Rh^+ ($CO)_2$. La réduction d'un mélange de dérivés de Rh et de CO supportés sur SiO_2 forme vraisemblablement des particules monométalliques de Rh(0) et de Co(0). L'interaction des deux métaux supprime le processus d'oxydation du R(0). Les résultats montrent que le Co(0) agit comme donneur d'électron et augmente ainsi la densité électronique des particules de Rh. Ces effets électroniques peuvent être mis en corrélation avec l'activité catalytique dans l'hydroformylation de l'éthylène. Les études IR montrent également que le noyau bimétallique $RhCo_3$ est conservé lorsque $RhCo_3(CO)_{12}$ est décarbonylé par thermolyse sur la surface de SiO_2 et qu'il régénère le cluster de départ par traitement avec CO à température ambiante. D'après les études IR, le Rh(0) supporté sur SiO_2 est un site actif dans l'hydroformylation, de plus le système $RhCo_3(CO)_{12}/SiO_2$ est lui même responsable de l'activité catalytique. Ce dernier présente une activité environ 20 fous supérieure à celle du catalyseur monométallique dérivé de $Rh_4(CO)_{12}/SiO_2$ dans l'hydroformylation de l'éthylène.

 $Rh\, support\'e\, sur\, SiO_2\ /\ oxydation\ de\ Rh(0)\ /\ RhCo_3(CO)_{12}\ support\'e\, sur\, SiO_2\ /\ conservation\ de\ RhCo_3\ /\ r\'eg\'en\'eration\ de\ RhCo_3(CO)_{12}\ /\ hydroformylation$

Introduction

The rhodium metal and rhodium compounds are very extensively studied and applied in the field of heterogeneous C_1 catalysis, because of their multifunctional activation toward CO and high catalytic activity. Regarding the nature of interaction of rhodium with the surfaces of oxides and CO, many investigators have de-

scribed their available experimental results on the basis of spectroscopic observations. Ambiguity and debate persist concerning the formation of surface $Rh^+(CO)_2$. Based on IR studies with Rh/Al_2O_3 , earlier investigators have proposed that the dissociative CO adsorption causes disruption of the Rh-Rh bond followed by oxidation of isolated Rh^0 atoms [1, 2], or that protons present as OH^- on the surface oxidize Rh^0 atoms [3, 4].

Recently, Gelin et al communicated IR isotopic evidence for a dissociative CO adsorption over rhodium particles supported on zeolite Y, which favors the mechanism of formation of Rh⁺ sites through CO adsorption [5]. Wong et al demonstrated that the oxidation of Rh⁰ to Rh⁺ in zeolite NaY occurs favorably by the combined action of H⁺ and CO as follows [6]:

$$Rh^0 + H^+ + 2CO \longrightarrow Rh^+(CO)_2 + 1/2 H_2$$
 (1)

In addition, they suggested that the following equilibria are established between rhodium ions, rhodium metal, H^+ and H_2 [6, 7].

$$Rh^{3+} + H_2 \longrightarrow Rh^+ + 2H^+$$
 (2)

$$Rh^{+} + 1/2 H_{2} \longrightarrow Rh^{0} + H^{+}$$
 (3)

As a result of the surface reactions involving electron transfer, the state of supported rhodium aggregates can be expected to affect catalytic behavior. Hence, establishing the correlation of the electronic state of supported metals with catalysis is of importance. Olefin hydroformylation provides a useful molecular probe of the active sites of heterogeneous catalysts, since it virtually implies a few elementary reactions and a few olefin- and CO-based reactions. A crucial step in the sequence of elementary reactions of hydroformylation is the insertion of CO. Previous works have postulated that the electronic state of oxide-supported rhodium active for CO insertion was +1 [8-11] and the Rh⁰ state was only responsible for CO dissociation and thus hydrocarbon formation [11]. Recent studies suggested that the linear CO adsorbed on both single Rh⁰-atom [12, 13] and Rh⁺-ion [12] sites can participate in CO insertion. What's more, the rhodium *gem*-dicarbonyl derived from $Rh_6(CO)_{16}/SiO_2$ was also demonstrated to be active for CO insertion and ethylene hydroformylation [14].

Over the last two decades, supported second metalcontaining rhodium catalysts have drawn great interest from many investigators towards the improvement of catalytic properties of monometallic rhodium for the formation of oxygenates in Fischer-Tropsch synthesis and for olefin hydroformylation. By combination with various second metal components such as Co, Fe, Zn, Mo, Mn, V and Ag as promoters, incorporated-rhodium catalysts display enhanced activities and selectivities for the formation of oxygenates [15–24]. The use of organobimetallic rhodium clusters as precursors leads to unusual catalytic performances for these reactions [25–29]. Nevertheless, the understanding of metal-metal' and metal-support actions in those systems is still poor. The obtained catalytic results are not interpreted satisfactorily in correlation with the actual state of supported metallic species.

The current work shows the situation of valence change for supported rhodium on SiO_2 by CO adsorption, and provides direct IR information on the disruptive oxidation of highly dispersed Rh_x crystallites to single isolated Rh^+ sites by surface OH^- groups. Our study is extended to the influence of second metals, such as cobalt in promoted rhodium catalysts and in cobalt-containing bimetallic rhodium cluster catalysts, on the reactivity of Rh^0 with surface OH^- , from an electronic

point of view. We discuss the stabilities of $\rm Rh^0$ and bimetallic Rh–Co clusters supported on $\rm SiO_2$ through an understanding of the interactions of metal–support and metal–metal'. We also compare monometallic and bimetallic rhodium active sites by studies of the surface chemical behaviors of $\rm Rh/SiO_2$, $(\rm Rh+Co)/SiO_2$ and $\rm RhCo_3(\rm CO)_{12}/SiO_2$ using IR spectroscopy and their catalytic properties in ethylene hydroformylation.

Experimental section

Rh₄(CO)₁₂ and RhCo₃(CO)₁₂ were synthesized using literature methods [30, 31]. The SiO₂ used was a silica 'Aerosil' purchased from Degassa with a surface area of 380 m²/g. n-Hexane for use as the solvent was distilled over P₂O₅ and stored under Ar over activated 5 Å molecular sieves. The gases used (H₂, CO, C₂H₄ and Ar) had a purity of 99.99%. Before admission into a reactor and an IR cell, they were passed through activated 5 Å molecular sieves and Mn/MnO to eliminate traces of water and oxygen.

The above two carbonyl clusters were employed as starting materials to prepare, by the impregnation technique under atmospheric Ar, supported rhodium catalysts on SiO₂ (60-80 mesh granule) which was predehydroxylated at 673 K under vacuum for 5 h. In situ IR monitoring showed that $Rh_4(CO)_{12}$ transforms to $Rh_6(CO)_{16}$, displaying carbonyl bands at 2080 s and 1802 m(br) cm⁻¹, on the SiO₂ surface, and RhCo₃(CO)₁₂ strongly physisorbs on SiO₂ [29, 32] after impregnation from n-hexane solution under Ar and removal of the solvent under vacuum at room temperature. The immediate formation of $Rh_6(CO)_{16}$ from $Rh_4(CO)_{12}$ on SiO2 by impregnation under vacuum has been reported earlier [33]. For the preparation of promoted rhodium catalysts, SiO₂ was first impregnated with an aqueous solution of Co(NO₃)₂ · 6H₂O followed by calcination in air at 673 K for 5 h. Then the resulting samples were subjected to impregnation of RhCl₃ · 3H₂O in water. The supported clusters as catalyst precursors were transferred to the reactor under Ar prior to catalytic tests.

The hydroformylation of ethylene was conducted under atmospheric pressure at 423 K in a dynamic reactor where 0.1 g of catalyst precursor with 1% Rh loading was charged. The chloride precursors were calcined in air at 673 K for 5 h and reduced in flowing H2 at 623 K for 2 h, after which H₂ was replaced by a mixture of C₂H₄, CO and H₂ (20:20:20 mL/min) at 423–473 K. The carbonyl precursors were decarbonylated in flowing H₂ or O₂ at 623 K for 2 h. Afterwards, H2 was directly replaced by the reaction gases at 423-473 K. O₂ was replaced by Ar and the catalysts were flushed under Ar for 1 h. Ar was finally replaced by the reaction gases at 423 K. To ensure differential conditions for the reaction, conversion of C₂H₄ was governed to below 10%. Data were taken 7 h after the initiation of the reaction. Both hydrocarbon and oxygenated products were analyzed on line with gas chromatography, using a 2 m length column of Porapak R and a flame ionization detector.

IR spectroscopy was used to determine the surface vibrational properties of supported catalysts and catalyst precursors. Each solid sample was pressed into a wafer of 20 mg ($d=15~\mathrm{mm}$) in air and placed in a double beam IR cell with CaF₂ windows, described in detail elsewhere [34], where the wafer was subjected to the desired treatments. In situ ethylene hydroformylation reactions over supported catalysts were monitored statically in the same IR cell, to which an equimolar gas mixture of C₂H₄, CO and H₂ at 78 kPa was admitted. All IR spectra were recorded at room temperature in the presence of gas phases by subtracting SiO₂ and gaseous contributions, on a Bio-Rad FTS-7 spectrometer.

The metal dispersion was evaluated by H_2 chemisorption stoichiometry measured on a ChemiSorb 2800 apparatus. The metal contents of the samples studied were determined by X-ray fluorescence spectroscopy.

Results

Studies on the interaction between Rh^0 and the SiO_2 surface

Four samples of 0.3 g of $Rh_6(CO)_{16}/SiO_2$ containing 0.2, 1, 2 and 5% Rh were treated in flowing H_2 at 623 K for 2 h and subsequently evacuated at 1.3×10^{-6} kPa and at 623 K for 10 min before irreversible H_2 adsorption measurements at 293 K. The rhodium dispersions obtained are listed in table I.

Table I. Rhodium metal dispersion on the surface of SiO₂.

% Rh	0.2	1	2	5
% Dispersion	76	41	32	23

In parallel, IR experiments were carried out using CO as a molecular probe to justify distinct metallic surface characters in relation to the amount of rhodium deposited. When H₂-reduced wafers of the four samples were exposed overnight to 3.9 kPa of CO after being evacuated at 293 K or treated by the same procedure as in the H₂ adsorption, the surfaces exhibited a set of regular IR spectra of adsorbed CO shown in figure 1. Each spectrum consisted of three types of adsorbed CO bands: geminal, linear and bridge. In the case of 0.2% Rh loading, for example, two bands at 2090 and $2\,026~\mathrm{cm}^{-1}$ are assigned to the rhodium gemdicarbonyl, $Rh^+(CO)_2$, and a shoulder at 2 053 cm⁻¹ and a broad band at 1871 cm⁻¹ are attributed to linear and bridged CO on Rh⁰. It is noteworthy that the linear CO and bridged CO bands shifted toward lower wavenumbers as the rhodium loading decreased, ie, as the rhodium dispersion increased. Increasing the metal loading resulted in an enhanced intensity ratio of linear and bridged CO bands to gem-dicarbonyl bands.

In contrast, once the same Rh/SiO₂ samples underwent 3 h or more of heating under vacuum at 623 K after H₂ treatment at 623 K, the adsorption of CO led to another set of IR spectra shown in figure 2. Their shapes were much modified, with a systematically increased intensity of gem-dicarbonyl bands with respect to linear and bridged CO bands. The linear and bridged CO bands disappeared on the Rh/SiO₂ samples with 1% and lower Rh loadings. By contrast, the sample with 5% Rh loading still presented dominant linear and bridged CO bands at 2036 and 1856 cm⁻¹. An intermediate spectrum of adsorbed CO was obtained with the 2% Rh sample which showed all three types of bands. The intensities of linear and bridged CO bands in figure 2 (c and d) were remarkably less than those in figure 1 (c and d).

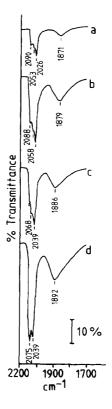


Fig 1. IR spectra of $Rh_4(CO)_{12}$ -derived Rh/SiO_2 under 3.9 kPa of CO for 12 h, after H_2 treatment at 623 K for 2 h and evacuation $(1.3 \times 10^{-6} \text{ kPa})$ at 623 K for 10 min. (a) 0.2% Rh; (b) 1% Rh; (c) 2% Rh; (d) 5% Rh.

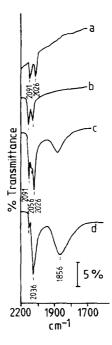


Fig 2. IR spectra of Rh₄(CO)₁₂-derived Rh/SiO₂ under 3.9 kPa of CO for 12 h, after H₂ treatment at 623 K for 2 h and evacuation $(1.3\times10^{-6}$ kPa) for 3 h. (a) 0.2% Rh; (b) 1% Rh; (c) 2% Rh; (d) 5% Rh.

IR studies pertinent to catalytic active valence on Rh/SiO_2

To shed light on the nature of the rhodium active site for hydroformylation, in situ IR spectroscopy was used to monitor an ethylene hydroformylation reaction over $\mathrm{Rh/SiO_2}$ run in a static IR cell.

Figure 3 shows the comparative IR spectra obtained on the surface before and after the reaction. A wafer of $\rm Rh_6(CO)_{16}/SiO_2$ containing 1% Rh was first treated under $\rm H_2$ at 623 K for 2 h followed by evacuation at room temperature for 10 min, then exposed to a CO atmosphere at 3.9 kPa. A spectrum similar to that in figure 1(b) resulted, containing the dominant bands at $2\,066$ and $1\,879$ cm⁻¹ due to Rh⁰-adsorbed CO, and shoulder bands at 2096 and 2036 cm⁻¹ attributed to small amounts of Rh⁺(CO)₂, as illustrated in figure 3(a). However, another identical wafer pretreated in the same manner did not display a pair of geminal CO bands upon exposure to 78 kPa of the reaction gases at room temperature (fig 3(b)). This indicates that the Rh^+ ions may be easily reduced to Rh^0 atoms by H_2 . The concomitant appearance of a very weak broad band centered at 1695 cm⁻¹ was noted in the spectrum. According to the literature [14, 35, 36] this band may be ascribed to adsorbed acyl species and propanal, which result from ethylene hydroformylation which might take place over Rh⁰/SiO₂ at room temperature. In addition, the linear CO band shifted from 2066 to 2051 cm⁻¹. This downward shift has been interpreted by several authors; it results from a decrease in the dipole-dipole interaction of the linear CO caused by dilution from adsorbed H and C_xH_y species on a neighboring rhodium atom [37], or from the coadsorption of H atoms and CO at individual exposed Rh⁰ sites [38–41]. In the latter case, the rhodium hydride species RhH(CO) and/or $Rh(H)_2(CO)$ are formed, which leads to increased π donation from the rhodium into the antibonding π orbital of the CO [42, 43]. Increasing the reaction temperature led to a marked enhancement of propanal as expected, and a continuous decrease in the dipole-dipole interaction of the linear CO because of more adspecies arising from the reaction. The fact that the band center, initially observed at 1 695 cm⁻¹, shifted to 1 705 cm⁻¹ after 3 h of the reaction at 423 K is interpreted in terms of superimposition of the bands for dominant amounts of propanal and small amounts of adsorbed acyl species on the surface, since the former increased with increasing reaction time and temperature.

IR studies on the electronic effects of cobalt on rhodium catalysts and bimetallic effects of Rh–Co cluster catalysts

In order to reveal the promotional action exerted by cobalt in promoted rhodium catalysts for the formation of oxygenates in ethylene hydroformylation, we determined the forms of adsorbed CO on the catalyst samples by IR spectroscopy. To ensure that the spectral variation caused by addition of cobalt was as striking as possible, all the samples were pretreated under $\rm H_2$ at 623 K for 2 h and subsequently evacuated at 1.3×10^{-6} kPa at the same temperature for 3 h, before CO adsorption at room temperature. Co/SiO₂ with 1% Co loading showed no adsorbed CO bands under CO. Rh/SiO₂

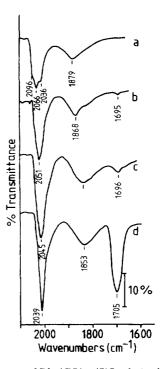


Fig 3. IR spectra of $Rh_4(CO)_{12}/SiO_2$ -derived samples (1% Rh loading) by H_2 treatment at 623 K for 2 h and evacuation (1.3 × 10⁻⁶ kPa) at 623 K for 10 min in a static IR cell. (a) under CO at 3.9 kPa for 2 h; under an equimolar mixture (78 kPa) of C_2H_4 , CO and H_2 : (b) at 293 K for 1 h; (c) at 331 K for 1 h; (d) at 443 K for 3 h.

with 1% Rh loading derived from either $Rh_4(CO)_{12}$ or $RhCl_3$, exhibited just gem-dicarbonyl features at 2 092 and 2 028 cm⁻¹ under CO, as mentioned above. Comparatively, addition of cobalt to Rh/SiO_2 gave rise to additional linear and bridged CO bands at 2 043 and 1 858 cm⁻¹, in high intensity apart from the gem-dicarbonyl bands which appeared weak under the same conditions, as shown in figure 4. The results indicated that the zerovalent rhodium atoms were still formed in the promoted catalysts despite the samples undergoing a longer heating evacuation at 623 K after H_2 reduction. This is in obvious contrast with the monometallic rhodium catalysts.

When the bimetallic carbonyl cluster RhCo₃(CO)₁₂ was directly used to prepare a cobalt-containing bimetallic rhodium catalyst, the adsorptive behavior of CO on the resulting catalyst differed much from that in the cases with Rh/SiO₂ and the promoted rhodium catalysts. In fact, after the precursor RhCo₃(CO)₁₂/SiO₂ had been decarbonylated under H_2 at 623 K for 2 h, adsorption of CO at 0.2 kPa and at room temperature resulted in two bands at 2028 and 1827 cm⁻¹ as shown in figure 5(b). They closely resemble the bands characteristic of RhCo₃(CO)₁₂ strongly physisorbed on SiO₂ (fig 5(a)) which we have recently characterized [32, 44]. This suggests that the initial cluster RhCo₃(CO)₁₂ was basically regenerated via recarbonylation of RhCo₃/SiO₂. Furthermore, it was surprisingly found that there was no spectral change when $\mathrm{RhCo_{3}(CO)_{12}/SiO_{2}}$ was subjected to oxidation under

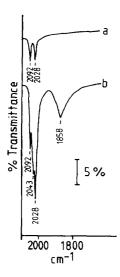


Fig 4. IR spectra after overnight exposure to 3.9 kPa of CO of the following precursor-derived samples (1% Rh loading) by $\rm H_2$ treatment at 623 K for 2 h and evacuation (1.3 × 10⁻⁶ kPa) at 623 K for 3 h. (a) Rh₄(CO)₁₂/SiO₂ or RhCl₃/SiO₂; (b)[RhCl₃ + Co(NO₃)₂]/SiO₂ (Co/Rh = 1:1).

atmospheric oxygen at 623 K for 2 h, followed by CO adsorption, as shown in figure 5(c). This indicates that an identical result is obtained on recarbonylation of the bimetallic catalyst surface to give the starting supported cluster regardless of the atmosphere used.

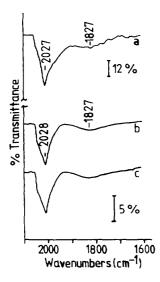


Fig 5. IR spectra of SiO_2 -supported $RhCo_3(CO)_{12}$. (a) $RhCo_3(CO)_{12}/SiO_2$ under vacuum $(1.3\times10^{-6}\ kPa)$; (b) under $0.2\ kPa$ of CO after 2 h of H_2 decarbonylation of $RhCo_3(CO)_{12}/SiO_2$ (1% Rh loading) at 623 K; (c) under $0.2\ kPa$ of CO after 2 h of O_2 decarbonylation of $RhCo_3(CO)_{12}/SiO_2$ (1% Rh loading) at 623 K.

Figure 6 presents the in situ surface IR spectra obtained during an ethylene hydroformylation reaction run at 78 kPa and at 423 K over the catalyst decarbonylated from $RhCo_3(CO)_{12}/SiO_2$ by H_2 in a static IR cell.

The carbonyl bands corresponding to the regenerated $RhCo_3(CO)_{12}/SiO_2$ under a CO pressure, remained essentially unchanged upon exposure of $RhCo_3/SiO_2$ to the reaction atmosphere at 423 K, except that trace amounts of $Rh_6(CO)_{16}/SiO_2$ appeared, showing a shoulder band at 2084 cm⁻¹. We have demonstrated that the production of $Rh_6(CO)_{16}$ in this situation is related to the dissociation of $RhCo_3(CO)_{12}$ on the SiO_2 surface under a higher CO pressure [32, 44].

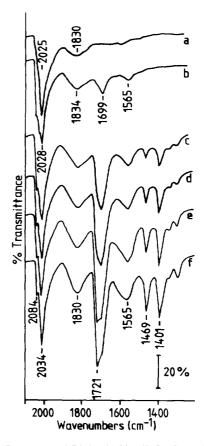


Fig 6. IR spectra of RhCo $_3$ (CO) $_{12}$ /SiO $_2$ -derived samples in a static IR cell. (a) RhCo $_3$ (CO) $_{12}$ /SiO $_2$ under vacuum (1.3 × 10 $^{-6}$ kPa); after exposure of H $_2$ decarbonylated RhCo $_3$ (CO) $_{12}$ /SiO $_2$ to an equimolar mixture (78 kPa) of C $_2$ H $_4$, CO and H $_2$ at 423 K for: (b) 15 min; (c) 3 h; (d) 5.5 h; (e) 15.5 h; (f) 108 h.

Rh₆(CO)₁₆/SiO₂ is known to be inactive for hydroformylation [13, 45, 46]. The band ascribed to SiO₂-adsorbed propanal and acyl species at 1699 cm⁻¹ and the bands due to SiO₂-adsorbed propanal at 1469 and 1401 cm⁻¹ were noticed to develop with reaction time. The upward shift of the band initially situated at 1699 cm⁻¹ to 1721 cm⁻¹ after 108 h of the reaction, is due to the presence of prevailing amounts of propanal over adsorbed acyl species on the surface. Because the recarbonylated catalyst under catalytic conditions can be identified as RhCo₃(CO)₁₂/SiO₂ and was essentially accompanied by the appearance and gradual increase of the hydroformylation products throughout the prolonged reaction, it is suggested that RhCo₃(CO)₁₂/SiO₂

Table II. Catalytic properties of SiO₂-supported catalysts^a in atmospheric ethylene hydroformylation^b.

Starting material	$Co:Rh$ $(Atomic\ ratio)$	$Activity^c \ (mol/Rh\ mol/min)$		$Selectivity \ (mol \ \%)$	
		C_2H_6	$Oxygenates^d$	Oxygenates	$n-C_3H_7OH$
$Co_2(CO)_8$		0	0	_	
$Rh_4(CO)_{12}$		0.42	0.37	47	0
RhCl ₃		0.25	0.20	44	0
$RhCl_3 + Co(NO_3)_2$	1:2	0.16	0.46	74	3
$RhCl_3 + Co(NO_3)_2$	1:1	0.57	0.91	61	1
$RhCl_3 + Co(NO_3)_2$	3:1	0.35	0.96	74	9
RhCo ₃ (CO) ₁₂		3.63	6.56	64	6
$RhCo_3(CO)_{12}^e$		5.32	9.95	65	8

^a Co/SiO₂ with 1.7% Co loading, the others with 1% Rh loading, pretreated under H₂ at 623 K; ^b at 423 K, c C₂H₄:CO:H₂ = 20:20:20 mL/min; ^c data were taken 7 h after the initiation of reaction; ^d C₂H₅CHO + n-C₃H₇OH; ^e pretreated under O₂ at 623 K.

is actively and stably responsible for the catalysis. In addition, a strange band at 1565 cm⁻¹ emerged on the surface immediately after initiation of the reaction and was concomitant with the formation of propanal. The attribution of this band remains unclear. We suspect that it might implicate a relatively stable hydroformy-lation intermediate adsorbed on supported bimetallic Rh–Co cluster catalyst because according to our work the use of either cobalt-containing bimetallic or cobalt-promoted rhodium catalysts in ethylene hydroformylation was always accompanied by the presence of this IR feature.

Catalytic investigations of SiO₂-supported monometallic and cobalt-containing rhodium catalysts

To establish a general comparison of catalytic performances of mono- and bimetallic catalysts in ethylene hydroformylation, Rh/SiO₂, (Rh+Co)/SiO₂ and $RhCo_3(CO)_{12}/SiO_2$ were tested under atmospheric pressure at 423 K. The data obtained are listed in table II. As compared with a RhCl₃-derived monometallic Rh/SiO₂ catalyst, added cobalt in the promoted rhodium catalysts enhanced the hydroformylation and hydrogenation rates, and improved significantly the hydroformylation selectivity. The exhibited activities to oxygenates were 2.3-4.8 times that of that Rh/SiO₂ catalyst, showing the significant promoting effects of cobalt on the catalysis of monometallic rhodium. Meanwhile the slight production of n-propanol was detected. The RhCo₃(CO)₁₂-derived catalysts exhibited an incomparable superiority, with considerably higher hydroformylation activities than the others. For the RhCo₃(CO)₁₂/SiO₂ system, it was very surprising to note that the catalyst derived by decarbonylation under O₂ at 623 K displayed even higher hydroformylation activity than the catalyst derived by decarbonylation under H_2 at 623 K. Relative to a $Rh_4(CO)_{12}$ -derived Rh/SiO₂ catalyst, the catalytic activities and selectivities of the RhCo₃(CO)₁₂-derived catalysts for the formation of oxygenates were increased respectively by 18-27 times and approximately 17%. Moreover they had a good catalytic stability during 115 h of reactions. The results indicated a probable Rh-Co bimetallic concerted role for the catalytic hydroformylation.

Discussion

In virtue of our IR results for CO adsorption on the $Rh_4(CO)_{12}$ - or $Rh_6(CO)_{16}$ -derived Rh/SiO_2 with rhodium loadings below 5%, the rhodium surface after H₂ thermal treatment, even though its loading is as low as 0.2%, gives rise to a mixture of rhodium gemdicarbonyl, $\ddot{Rh^0}\text{-}adsorbed$ linear CO and $Rh^0\text{-}adsorbed$ bridged CO under CO as shown in figure 1. This complex CO adsorption has also been observed on Rh/SiO₂ by other authors [12, 47-49]. Combining the measurements of H₂ chemisorption with the IR observations, it is deduced that decreasing rhodium loading results in the increase of rhodium dispersion and the enhancement of Rh⁺(CO)₂. Therefore, the extent to which metallic rhodium particles are oxidized to Rh⁺ ions on a partially dehydroxylated SiO₂ surface is associated with rhodium dispersion. More dispersed metal atoms are more easily oxidized, according to the intensity ratios of gem-dicarbonyl bands to Rh⁰-adsorbed CO bands in figure 1. Combining the present results with the work of Basu et al [4], the proportion of oxidized Rh⁰ on SiO₂ is lower than that on Al₂O₃. Nevertheless, it is unclear whether CO, serving as an IR probe, is instrumental in the oxidation. Our IR data provide direct evidence in favor of the oxidative pathway of highly-dispersed rhodium by surface OH⁻ or H⁺. After the freshly H₂reduced Rh/SiO₂ samples have been treated under vacuum $(1.3 \times 10^{-6} \text{ kPa})$ at 623 K for 3 h. Rh⁰ atoms actually undergo strong interaction with the acidic OH⁻ groups on the SiO₂ surface, which can effectively form Rh⁺ sites:

$$2 Rh^0 + 2H^+ \longrightarrow 2 Rh^+ + H_2$$
 (4)

This produces much more atomically-dispersed Rh⁺ sites than with a temperature of 293 K. As a consequence, a greatly enhanced intensity of gem-dicarbonyl bands relative to linear and bridged CO bands was observed in figure 2. Especially on the surface of less than 1% Rh loading, Rh⁰ atoms seemed to convert completely to Rh⁺ ions after having interacted with OH⁻ groups, the spectra showing only doublet features under CO. The small proportion of Rh⁺(CO)₂ with the gem-dicarbonyl shoulder bands observed in figure 1 may also result from Rh⁰ oxidation after 10 min of evacuation at 623 K. Comparing the two sets of IR spectra in figures 2

and 3, we infer that the direct oxidation of Rh⁰ by surface OH^- play a key role in the formation of $Rh^+(CO)_2$, since the proportion of the latter increases with increasing oxidizability of OH⁻ at a given Rh loading. Here it is worth recalling that only Rh⁺(CO)₂ is formed under CO on reduced Rh/Al₂O₃ at 2.2% Rh loading [4]. That means that the surface OH⁻ of Al₂O₃ is a stronger oxidant than that of SiO₂. In contrast, the interaction of CO with highly dispersed SiO₂-supported rhodium fails to lead to appreciable formation of Rh⁺(CO)₂ within a reasonable time as seen in figure 1(a). Moreover, the amount of Rh⁺(CO)₂ on Rh/SiO₂ develops to just a small extent with increasing CO pressure [4, 12]. Hence, the $Rh^0 \to Rh^+$ transition is highly dependent on the oxidizability of surface OH⁻, and appears independent of the adsorption of CO in the presence of both surface OH⁻ and gaseous CO. We suggest that the interaction mechanism of Rh⁰ with surface OH⁻ and CO involves the oxidation of Rh⁰ to Rh⁺ by surface OH⁻ before CO coordination to form $Rh^+(CO)_2$.

In this work, although the Rh/SiO₂ catalyst with 1% Rh loading prepared from $Rh_4(CO)_{12}$ by H_2 treatment and 10 min of evacuation at 623 K, yielded some Rh⁺(CO)₂ under a CO atmosphere as shown in figure 3(a), it instead produced only linear and bridged CO adsorbed on Rh⁰/SiO₂ under a mixture of C₂H₄, CO and H₂. This shows that small amounts of Rh⁺ ions formed probably via the oxidation of Rh⁰ atoms by surface OH⁻ during the short evacuation treatment at 623 K, are rereduced by H₂ at a temperature as low as 293 K. On the other hand, it appears to further demonstrate that surface OH⁻ is responsible for the oxidation of Rh⁰ independently of the dissociative CO adsorption. We speculate that Rh/SiO₂ catalysts resulting from rhodium compounds by H₂ decarbonylation or reduction normally contain only Rh⁰ atoms on the surface if the ultimate evacuation process is not involved prior to CO adsorption. The result is consistent with that of Basu et al who have assumed not only the involvement of surface OH⁻ in the disruptive oxidation of Rh_x crystallites to give $Rh^+(CO)_2$ in equation 5, but also its inverse reaction [4].

$$1/x Rh_x^0 + OH^- + 2 CO$$

 $\rightarrow Rh^+(CO)_2 + 1/2 H_2 + O^{2-}$ (5)

Also in agreement with the involvement of H⁺ in the oxidation and the interconversion between Rh⁰ and Rh⁺ on zeolite Y [7], the introduction of H₂ enables equilibrium 3 to shift to the right on SiO₂. It is logical to assess that the reduction of Rh⁺ proceeds more easily on SiO₂ than on zeolite Y and Al₂O₃. At the same time, several groups have demonstrated that in the presence of $CO + H_2$, the formation of $Rh^+(CO)_2$ on Rh/SiO₂ and Rh/Al₂O₃ is suppressed and the observed IR spectra exhibit only linear and bridged CO bands [39-41, 50]. In our case, since the observed Rh⁰adsorbed CO species were obviously concomitant with the formation of propanal on the surface, and no trace of $Rh^+(CO)_2$ was invoked with the increase of reaction temperature up to 423 K, the catalytic hydroformylation active site is likely to be Rh^0/SiO_2 .

Insomuch as H₂ is capable of preventing the oxidation of metallic rhodium particles on the surface,

Rh/SiO₂ catalysts pretreated with H₂ should present all their surface rhodium atoms available as active sites under a hydroformylation atmosphere.

The view of zerovalent rhodium as the heterogeneous hydroformylation active site has also been claimed by other groups. Takahashi et al, who studied the zeolite Y-supported rhodium system by means of IR and XPS, indicated that the catalytic activity for ethylene hydroformylation can be considerably enhanced only when $Rh^+(CO)_2$ is reduced with H_2 to metallic rhodium particles [13]. Detailed research by Chuang and Pien on $\mathrm{Rh/SiO_2}$ catalysts treated in different conditions showed using IR spectroscopy that the linear CO adsorbed on both Rh⁰ and Rh⁺ sites participates in CO insertion, leading to the formation of propanal from C_2H_4 and H_2 [12]. Although certain Rh⁺ sites on which specific CO groups are adsorbed and coordinated can become active for hydroformylation [12, 14], reduced Rh/SiO₂ catalysts cannot give Rh⁺ species under steady catalytic hydroformylation conditions and Rh⁺ species, if any, are readily reduced under a H₂-containing atmosphere. Moreover, supported Rh⁺ species display much lower hydroformylation activity than supported Rh⁰ under atmospheric pressure [12, 14]. Accordingly, only the Rh⁰ active site is of popular catalytic significance.

With regard to the promotional roles of second metals on the catalysis, addition of cobalt to Rh/SiO₂ does indeed influence the electronic state of rhodium according to the IR observations. Under oxidation conditions, namely through surface evacuation treatment at 1.3×10^{-6} kPa and 623 K, Rh⁰ completely converts to Rh⁺ on SiO₂, exhibiting just the geminal CO bands under CO, whereas the oxidation of Rh⁰ in the presence of cobalt is strongly inhibited, for the intense adsorbed linear and bridged CO bands appear under CO, as shown in figure 4(b). Thus, cobalt atoms in the promoted catalysts can be viewed as electron donors to interact effectively with rhodium atoms and thus to increase the electron density of rhodium metal ensembles. In this manner the scission of the Rh-Rh bond due to oxidative addition of surface OH⁻, resulting in isolated Rh⁺ ions, can be prevented. In order to explain the promotion of catalytic formation of oxygenates in ethylene hydroformylation, we suggest that Co⁰ atoms exert an electron-donating action on Rh⁰ atoms in the promoted catalysts. A similar promoting effect of cobalt on various noble metal catalysts for the formation of oxygenates in the CO + H₂ reaction and for hydroformylation, has been observed by other authors [15, 16]. As for the oxidation state of the metals in the actual promoted catalysts and the nature of such supported catalysts, it is necessary to cite the pertinent work of van't Blik et al concerning the temperature-programmed reduction (TPR) and temperature-programmed oxidation (TPO) of SiO_2 -supported (Rh + Co) systems [51]. During a TPR process up to 623 K, the reduction of cobalt ions such as Co₃O₄ and CoO is facilitated by the presence of rhodium. Both rhodium and cobalt metallic particles are readily formed in cobalt-promoted rhodium catalysts after reduction at 623 K. They are not isolated from each other but are in close contact on the surface.

It appears much more interesting to discuss the surface chemical behavior of SiO_2 -supported $RhCo_3(CO)_{12}$

and the promotional role of cobalt in the bimetallic cluster in relation to the catalytic results in ethylene hydroformylation. In virtue of our IR observations, the production of surface carbonyls having the bands at 2028 and $1\,827\,\mathrm{cm}^{-1}$, after $\mathrm{RhCo_3(CO)_{12}/SiO_2}$ has been decarbonylated under either H₂ or O₂, can be interpreted by the regeneration of $RhCo_3(CO)_{12}$ present in the strongly physisorbed form from RhCo₃/SiO₂. The RhCo₃ framework is hence suggested to be well-retained on the surface in spite of the drastic calcination treatments. This is contrary to the case of $\mathrm{Rh_6(CO)_{16}/SiO_2}$ where the Rh₆ framework is not retainable on the surface but instead agglomerates into metallic rhodium particles upon decarbonylation under the same conditions [52]. It is worth pointing out that bimetallic particles are generally readily oxidized to monometallic components. Many examples have been shown of segregation of supported bimetallic catalysts and concomitant oxidation of metallic particles after thermal treatments under oxygen atmospheres [51, 53-55], among which a bimetallic Rh-Co catalyst was nearly completely converted to $\mathrm{Rh_2O_3}$ and $\mathrm{Co_3O_4}$ on $\mathrm{SiO_2}$ after TPO in 5% O₂/He up to 623 K [51]. However, the RhCo₃ cluster was found to remain very stable on SiO₂ after 2 h of treatment at 623 K under atmospheric oxygen in our case. This surprising result seems to indicate particular strong RhCo₃-support and Rh-Co interactions that are able to preserve the RhCo3 framework and prevent the bimetallic cluster from O_2 oxidation. In fact, no Rh⁺ or Rh³⁺ fragment was detected over RhCo₃/SiO₂ under CO following the oxidation treatment. In contrast, Rh+(CO)₂ was more or less discerned over cobalt-promoted Rh/SiO₂ under CO after reduction followed by oxidation under vacuum. In order to understand the cause of stabilization of RhCo₃ on SiO₂, we have recently advanced a hypothesis concerning a particular strong cluster-support interaction, via nucleophilic attack of surface oxygen on the cobalt atoms of RhCo₃ with the synergetic electron-donating action of cobalt atoms to rhodium atom [29, 32]. This kind of interaction may prevent the Rh-Co bond from thermal destruction and oxidative addition by surface OH⁻ as well as dissociation by CO. Furthermore, increasing the temperature results in an enhancement of the RhCo₃-SiO₂ interaction so as to further stabilize the RhCo₃ cluster [44]. Yokoyama and Ichikawa et al previously reported the interactions of carbonyl Rh-Co clusters with carbon and Al₂O₃ by an EXAFS study [56, 57]. They suggested that the $RhCo_3$ and Rh_2Co_2 cluster frameworks could be preserved on both kinds of surfaces, concomitant with the metal-oxygen bonding, after H₂ treatment at 673 K. This is consistent with the present observations with $RhCo_3(CO)_{12}/SiO_2$.

The above interpretation of surface chemistry gains support from the results of the catalytic investigation. The enormous difference in hydroformylation activity between the $RhCo_3(CO)_{12}$ -derived catalysts and the cobalt-promoted catalysts would arise from the different natures of the two categories of metallic surfaces. The fact that the former display much higher catalytic activities than the $Rh_4(CO)_{12}$ -derived catalyst seems to result reasonably from the preservation of the bimetallic $RhCo_3$ cluster on the surface, in agreement with the IR characterization results. Although the promotion of

added cobalt to Rh/SiO₂ results in a significant increase in catalytic activity, on the basis of our IR results and the literature the surface species characterized do not involve bimetallic Rh-Co particles or RhCo₃ clusters. In contrast, RhCo₃(CO)₁₂/SiO₂ is not only regenerable by exposure to CO after decarbonylation, but also stable under catalytic hydroformylation conditions, as evidenced by in situ IR study. The convincing results of in situ IR monitoring demonstrate that the molecular SiO₂-supported RhCo₃(CO)₁₂ is itself catalyticallyactive for ethylene hydroformylation. The observed high activity and stability are believed to be attributed to the supported bimetallic cluster. The reason why thermal decarbonylation under O₂ results in an increased hydroformylation activity, with respect to thermal decarbonylation under H₂ at the same temperature, for RhCo₃(CO)₁₂/SiO₂, remains unknown. It might be related to the increase in the RhCo₃ cluster dispersion on the surface after O_2 treatment.

Conclusions

- 1. The oxidation chemistry of Rh^0 on SiO_2 under CO can be translated by the oxidation of highly-dispersed metallic rhodium particles to isolated Rh^+ by surface OH^- , which converts to $\mathrm{Rh}^+(\mathrm{CO})_2$ after adsorbing CO, irrespective of dissociative CO adsorption on Rh^0 . It is suggested that SiO_2 -supported rhodium catalysts derived from $\mathrm{Rh}_4(\mathrm{CO})_{12}$ or $\mathrm{Rh}_6(\mathrm{CO})_{16}$ by H_2 decarbonylation, contain only Rh^0 on the surface, which is an active site for hydroformylation.
- 2. In cobalt-promoted rhodium catalysts, Co^0 behaves as an electron donor to Rh^0 to increase the electron density of metallic rhodium particles. The interaction of the second metal with Rh^0 significantly promotes $\mathrm{Rh}^0/\mathrm{SiO}_2$ catalysis for ethylene hydroformylation. However, the conventional preparative technique cannot lead to the formation of bimetallic Rh–Co catalysts from two different metal compounds.
- 3. By use of $RhCo_3(CO)_{12}$, the bimetallic $RhCo_3$ framework has been found to be preserved intact on the SiO_2 surface, even if $RhCo_3(CO)_{12}/SiO_2$ is decarbonylated under O_2 at 623 K. $RhCo_3/SiO_2$ is readily recarbonylated to $RhCo_3(CO)_{12}/SiO_2$. Under catalytic conditions, $RhCo_3(CO)_{12}/SiO_2$ has been characterized to be active and stable for ethylene hydroformylation. $RhCo_3(CO)_{12}/SiO_2$ exhibits considerably enhanced hydroformylation activity as compared with Rh/SiO_2 .

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